nearly 50% open surface, that is, not intercepted by wires and a total thickness (woven wires plus emulsion) of around 100 μm.

2. *Pastes*: The pastes are the vehicles that carry the active material to the wafer surface. Their composition is formulated to optimize the behavior during printing. A paste for the metallic contacts of the solar cell is composed of the following:

   Organic solvents that provide the paste with the fluidity required for printing
   Organic binders that hold together the active powder before its thermal activation
   Conducting material, which is a powder of silver composed of crystallites of a size of tenths of microns; for the *p*-contact, aluminum is also present. This amounts to 60 to 80% in weight of the paste
   Glass frit, 5 to 10% in weight, a powder of different oxides (lead, bismuth, silicon etc.) with a low melting point and high reactivity at the process temperature, that enables movement of the silver grains and etches the silicon surface to allow intimate contact.

   The paste composition is extremely important for the success of the metallization and is critically linked to the heat treatment.

3. *Printing*: Figure 7.9 illustrates the process of printing a paste through the patterned emulsion on a screen. The screen and the wafer are not in contact, but a distance apart called the *snap-off*. After dispensing the paste, pressure is applied to the squeegee, which can be made of metal or rubber: this puts the screen in contact with the wafer. The squeegee is then moved from one side of the screen to the opposite one, dragging and pressing the paste in front of it. When an opening is reached, the paste fills it and sticks to the wafer, remaining there after the squeegee has passed and the screen has elastically retired.

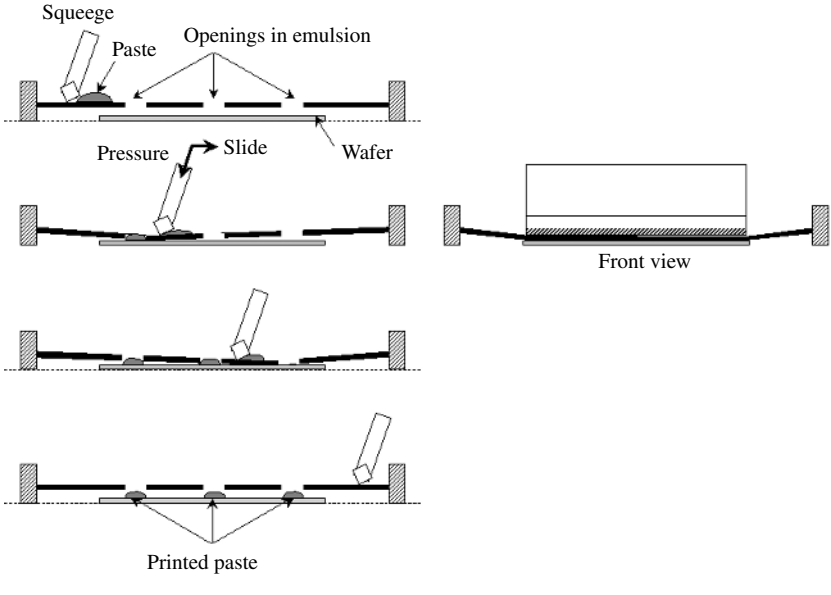

Figure 7.9 Illustration of a printing sequence